

## Notic of Referenc s Cit d

Application/Control No. 09/696,955

No.

Applicant(s)/Patent Under Reexamination TAMURA ET AL.

Examiner

Matthew A. Anderson

Art Unit 1765

Page 1 of 1

## **U.S. PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name Classi		fication
	Α	US-6284093 B1	09-2001	Ke et al.	156	345
	В	US-6299982 B1	10-2001	Tamatsuka et al.	428	446
	С	US-6190495 B1	02-2001	Kubota et al.	156	345
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## **NON-PATENT DOCUMENTS**

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
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\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)

Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.